"semiconductor substrate while minimizing the diffusion of dopant atoms" by use of "a pulsed beam of particles having a duration" of less than or equal to  $10^{-4}$  seconds, and between  $10^{-10}$  seconds and  $10^{-4}$  seconds, respectively.

There are numerous differences between what is claimed by the Applicants in amended claims 1 and 53 and what is disclosed by Asakawa. A summary of those differences are as follows:

	Claims 1 and 53	<u>Asakawa</u>
substrate:	semiconductor	insulating glass (quartz)
diffusion:	minimized	not minimized
source:	pulsed particle beam	continuous beam
coverage:	small amorphous region	entire surface of substrate
duration:	not more than 10 <sup>-4</sup> second	none recited

The significance of these differences is highly relevant to whether or not what is claimed in claims 1 and 53 is obvious from Asakawa.

A <u>semiconductor substrate</u> is a **good thermal conductor**, <u>quartz</u> is a **poor thermal conductor**;

In the application of Claims 1 and 53 <u>minimization of diffusion is necessary</u> to not destroy the component being formed, <u>Asakawa's purpose</u> is to form a single crystal thus has **no reason to minimize diffusion**;

In the application of Claims 1 and 53 a <u>pulsed particle beam is necessary</u> to control diffusion, <u>Asakawa has no reason to control diffusion</u> thus he **no** reason to consider using of anything other than a continuous beam;

In Claims 1 and 53 a <u>small amorphous region</u> is the target of the pulsed beam, <u>Asakawa's</u> focus is the **entire surface**; and

In claims 1 and 53 the period of exposure is <u>not more than 10<sup>-4</sup> second</u>,

<u>Asakawa</u> does not recite beam duration since application **can tolerate seconds** 

of exp sure.

Additionally, each of Claims 1 and 53 call for the activation of the amorphous

region, whereas Asakawa's purpose is crystallization of a single silicon layer on the

surface of quartz. If the method disclosed by Asakawa were used on the substrate

called for in Claims 1 and 53, the intended final structure would be destroyed.

For all of these reasons Claims 1 and 53 as amended can not be said to be

obvious from Asakawa and thus Claims 1 and 53 are in condition for allowance.

Given that each of the other rejected claims are dependent from either Claim 1

or Claim 53, they too a patentably distinguishable from Asakawa.

All of the claims are now in condition for allowance.

Favorable action is respectfully requested.

Respectfully submitted,

Andrew M. Hawryluk et., al

hv

Allston L. Jones

Reg. No. 27,906

Peters, Verny, Jones & Schmitt, L.L.P.

385 Sherman Ave., Suite 6

Palo Alto, CA 94306 Voice: 650/324-1677

FAX: 650/324-1678

e-mail: alj888@aol.com

January 13, 2003

4